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(12) **United States Design Patent**
Lee et al.

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- (54) **NASAL MASK**
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- (73) Assignee: **GALEMED CORPORATION**, Yilan County (TW)
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- (51) **LOC (12) Cl.** **29-02**
- (52) **U.S. Cl.**
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- (58) **Field of Classification Search**
USPC D24/108, 110, 110.5, 111, 112, 128, D24/110.4, 110.1, 127, 129
CPC A61M 16/0666; A61M 16/0672; A61M 2202/0208; A61M 16/0683; A61M 16/06; A61M 2210/0618; A61M 16/0616; A61M 16/0622; A61M 16/0633; A61M 16/00
See application file for complete search history.

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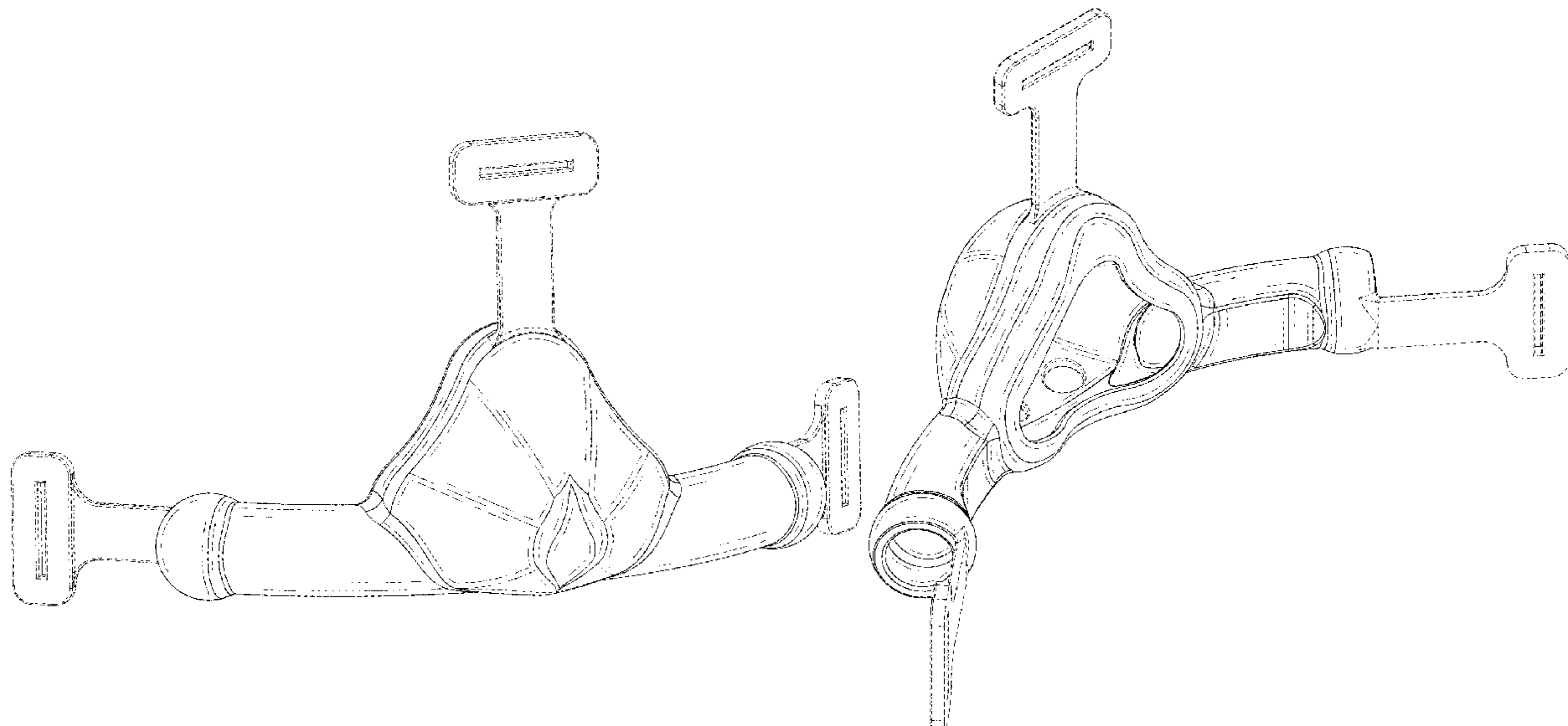
(57) **CLAIM**

The ornamental design for a nasal mask, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a nasal mask showing our new design;
FIG. 2 is a front view thereof;
FIG. 3 is a rear view thereof;
FIG. 4 is a left side view thereof;
FIG. 5 is a right side view thereof;
FIG. 6 is a top view thereof;
FIG. 7 is a bottom view thereof; and,
FIG. 8 is a second perspective view showing the nasal mask.
The broken lines in the drawings illustrate portions of the nasal mask that form part of the claimed design.

1 Claim, 8 Drawing Sheets



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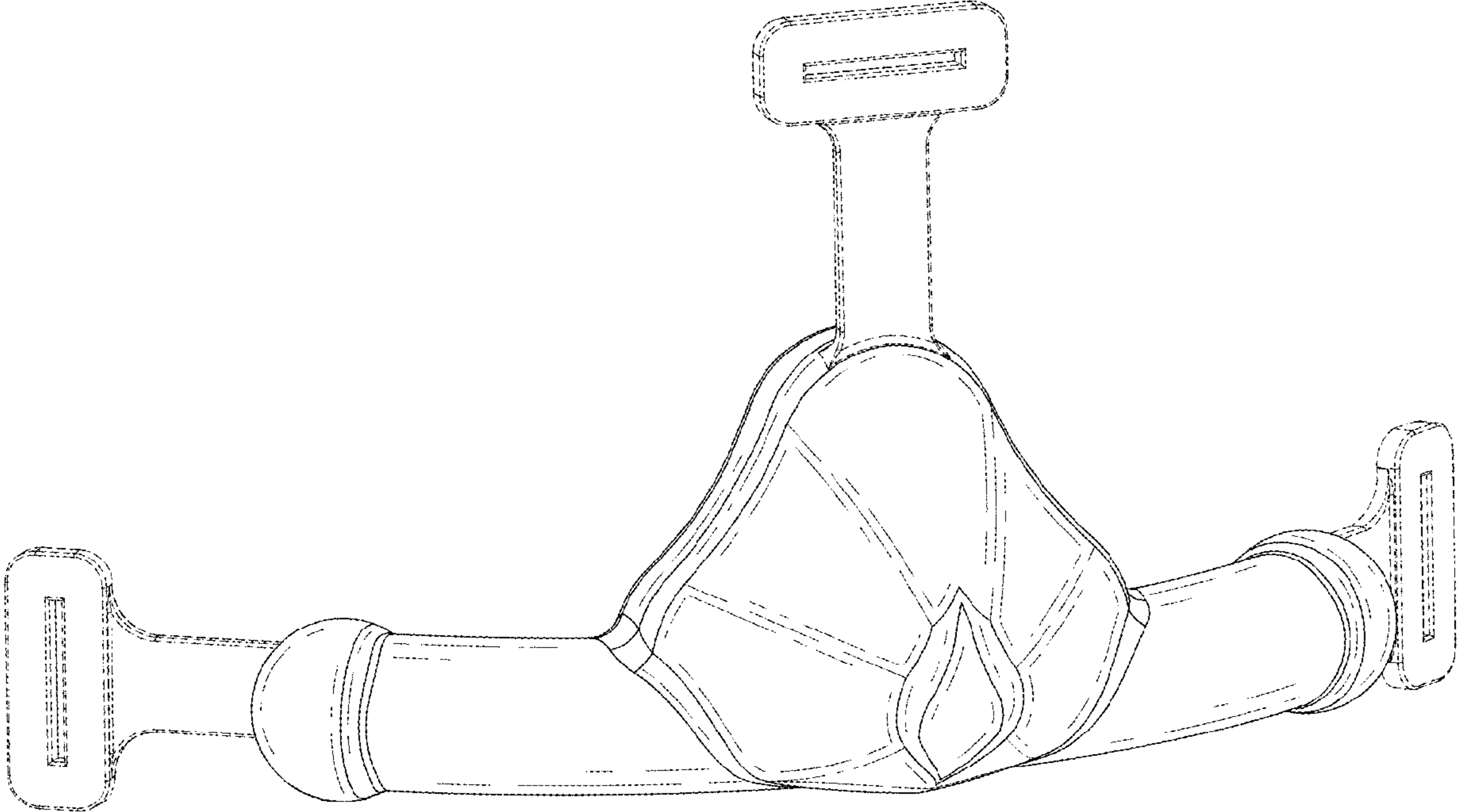


FIG.1

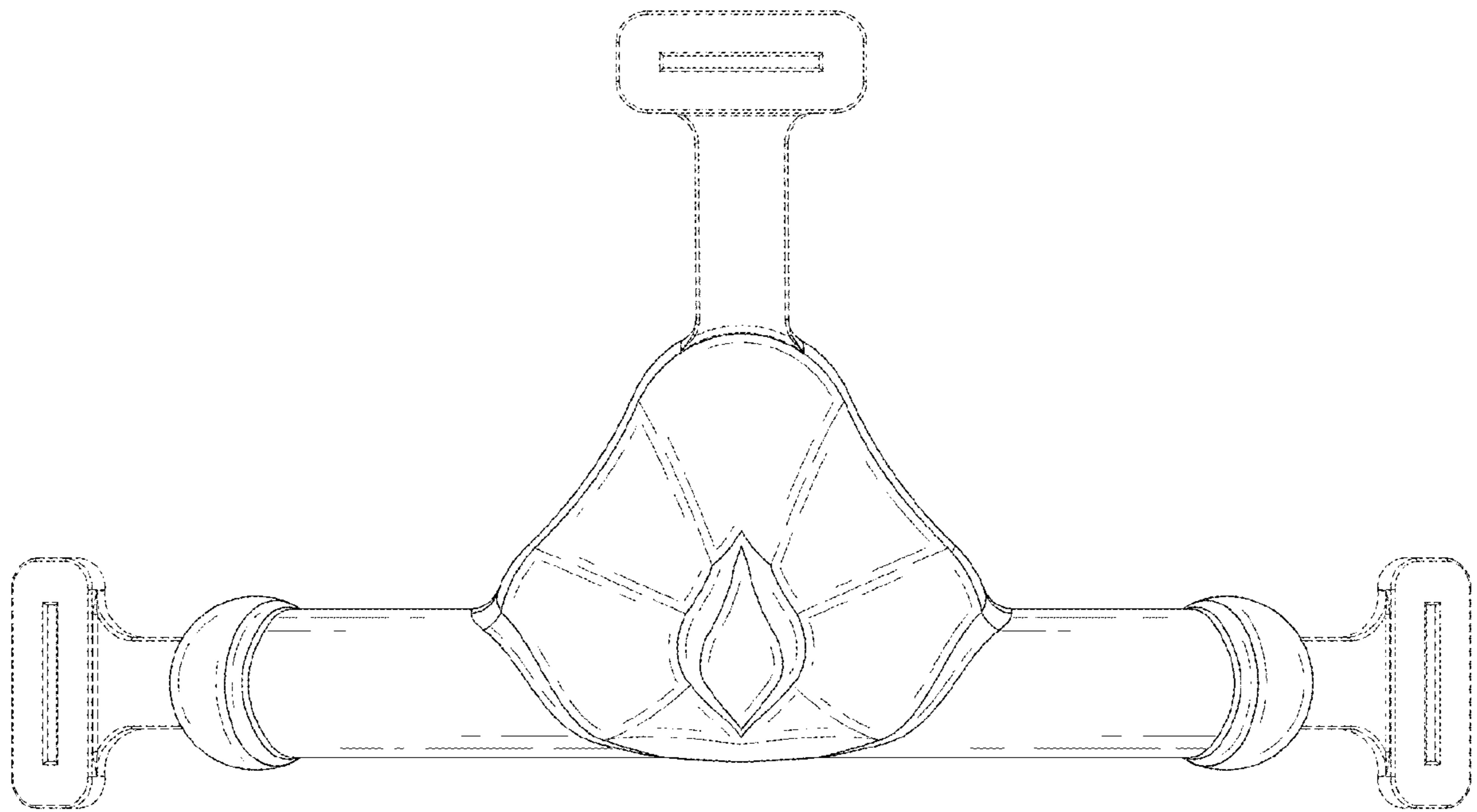


FIG.2

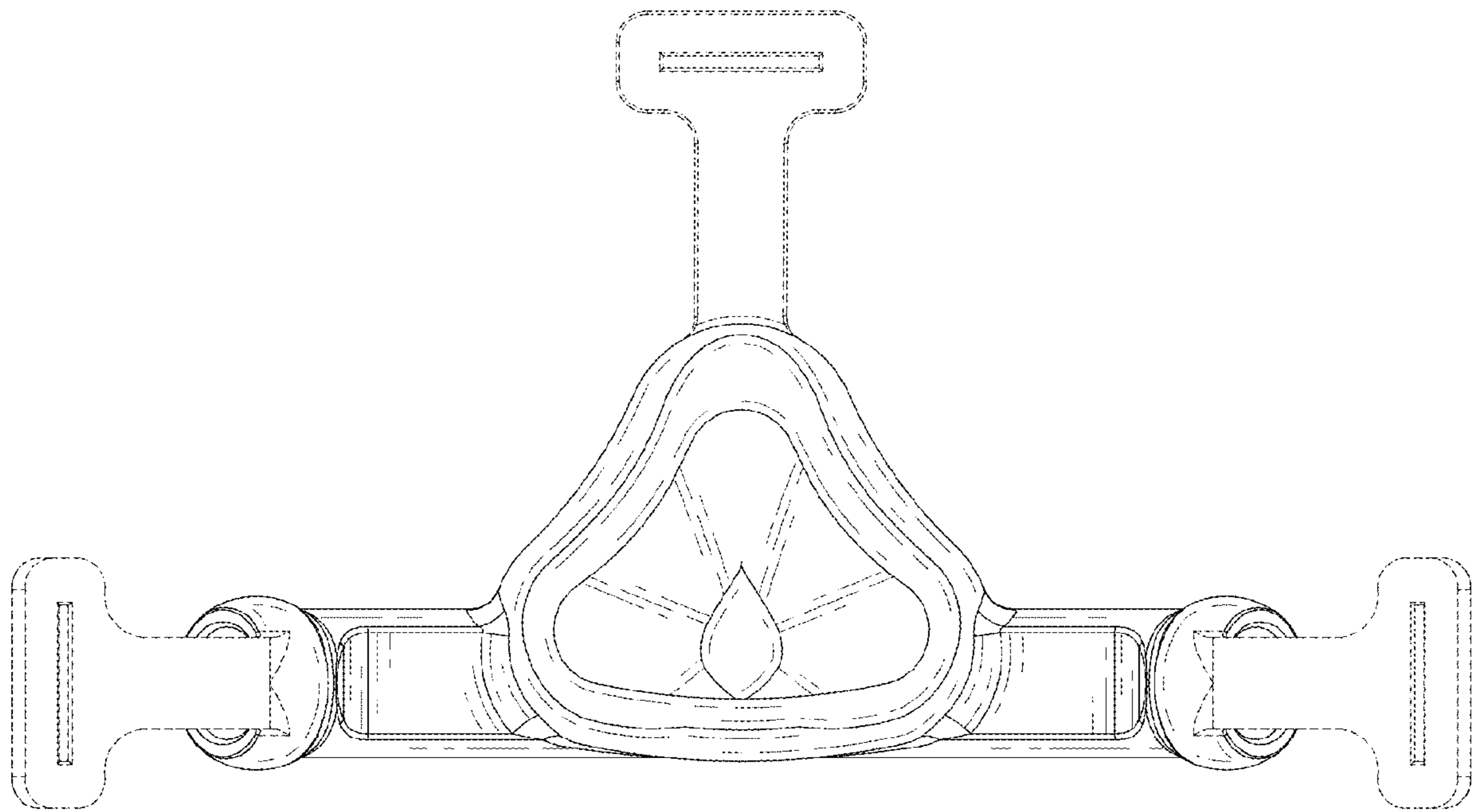


FIG.3

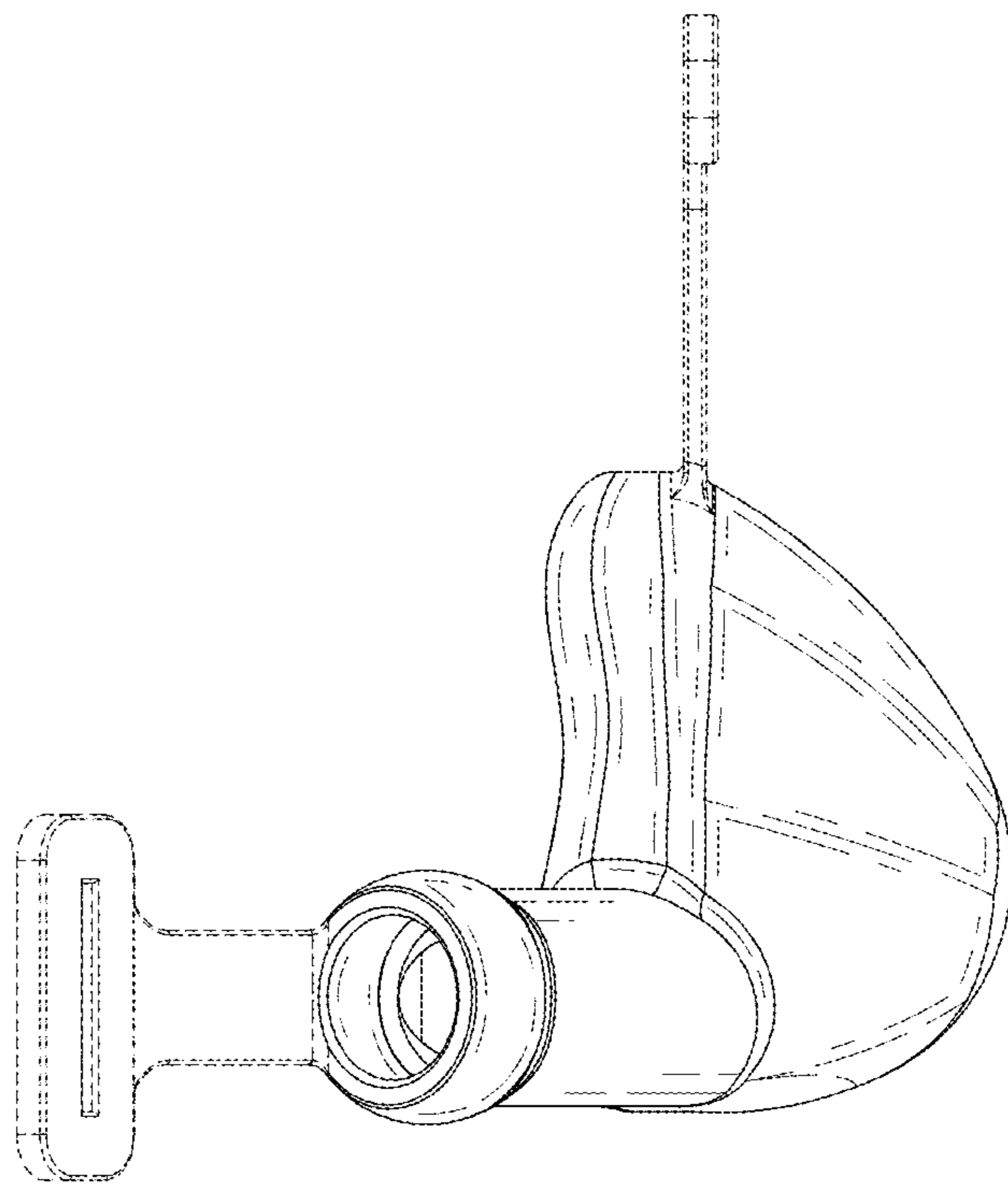


FIG.4

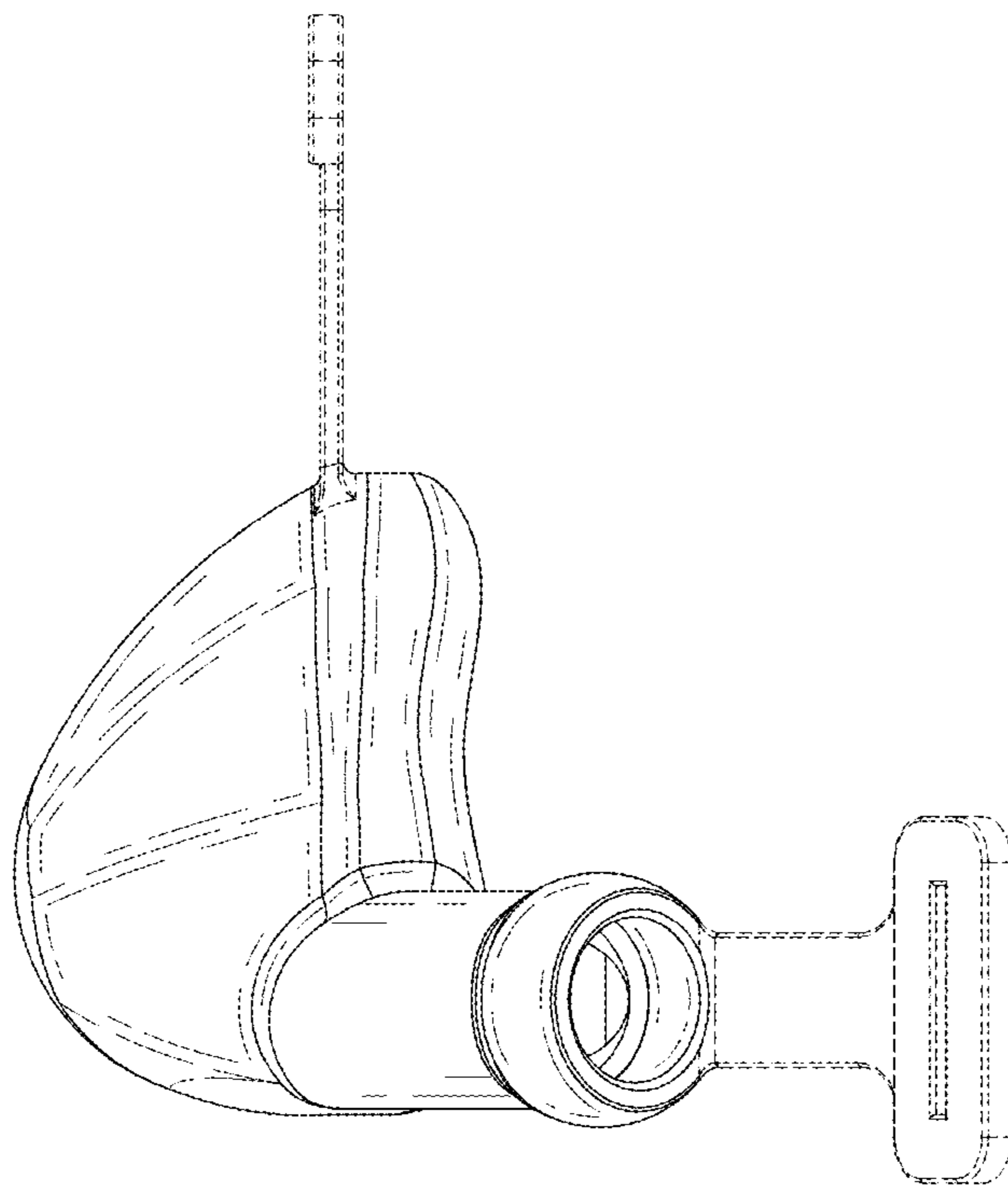


FIG.5

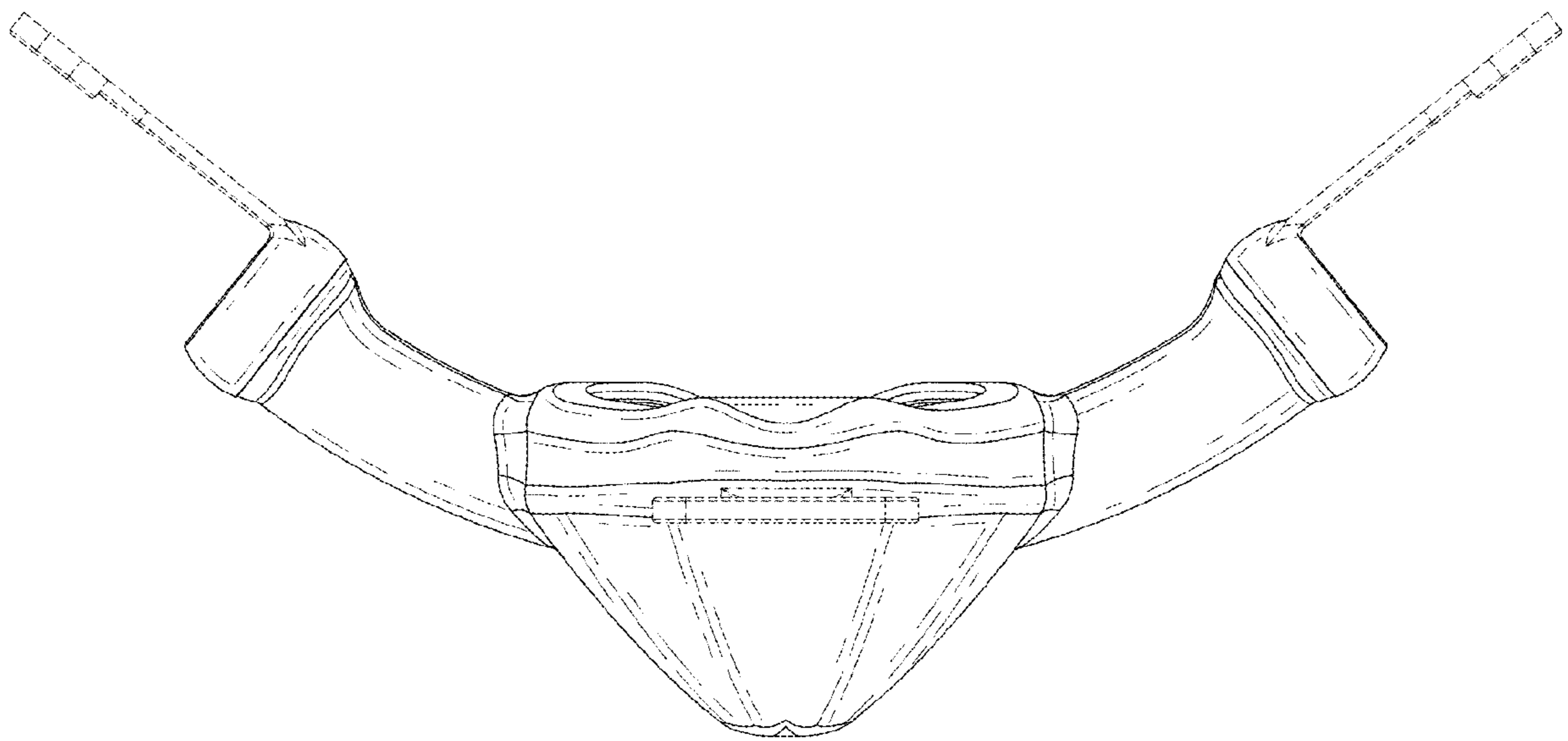


FIG.6

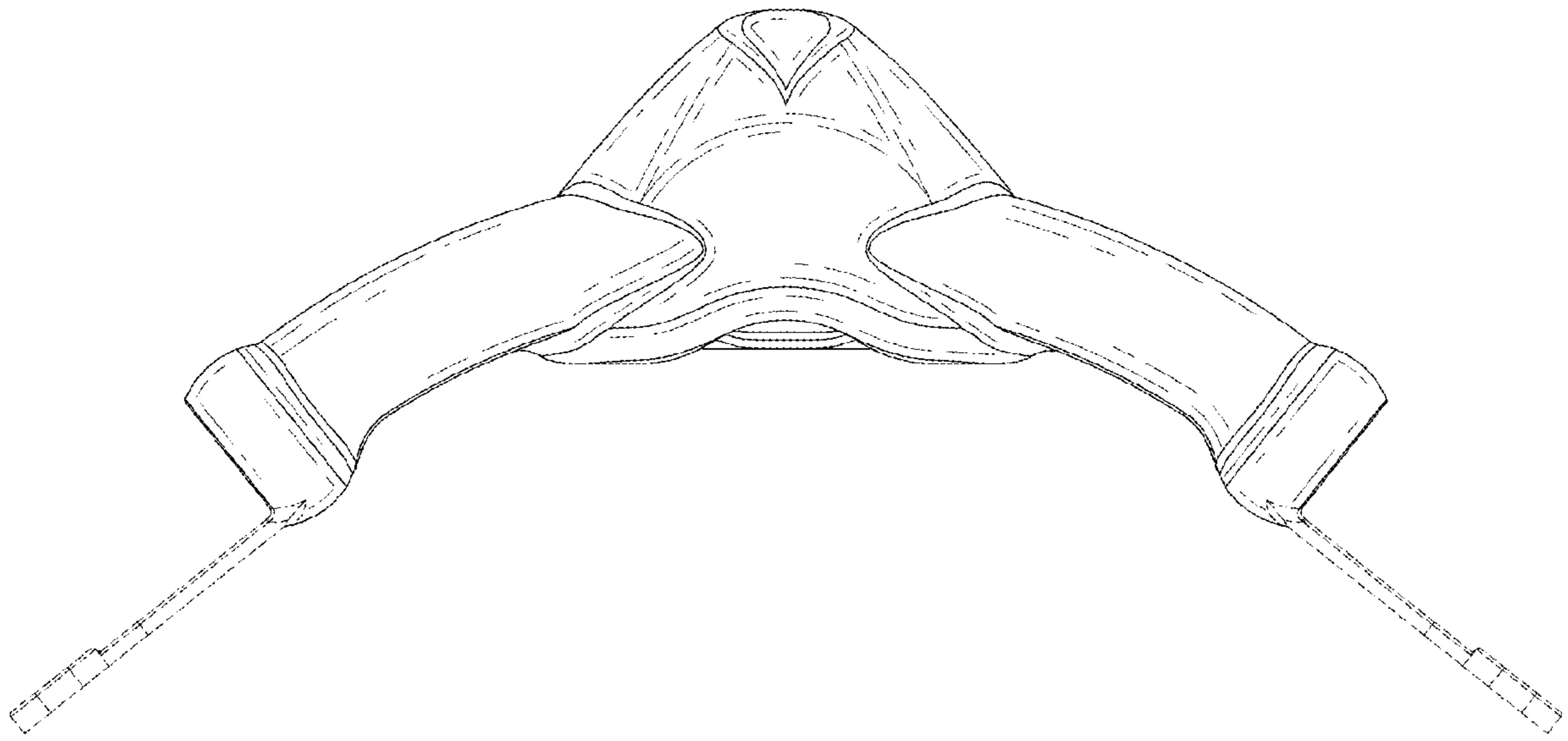


FIG.7

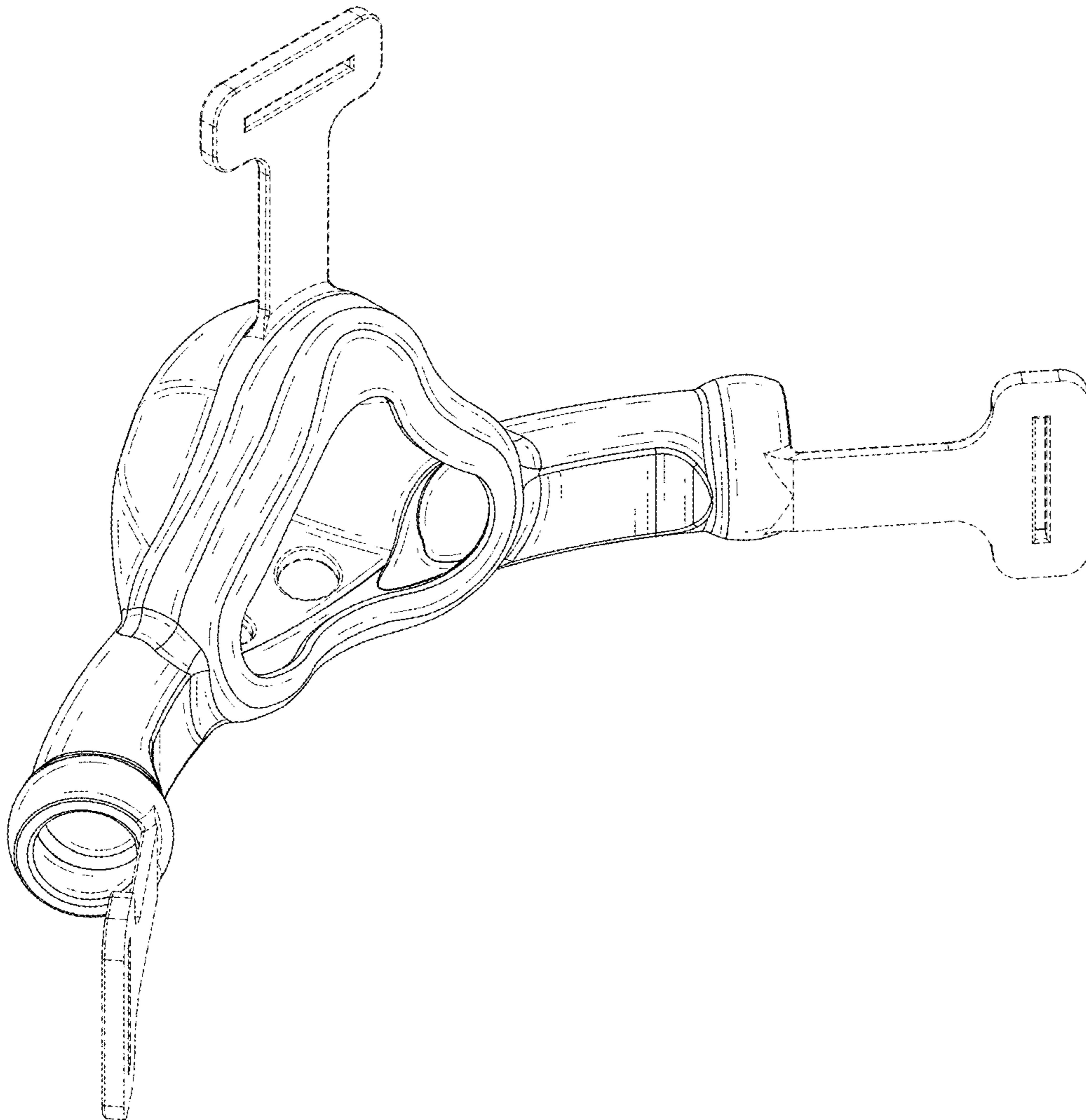


FIG.8